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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/669,864	09/24/2003	Dana A. Gronbeck	51757	5134
21874	7590 03/29/2005		EXAMINER	
EDWARDS & ANGELL, LLP			WILLIAMS, ALEXANDER O	
P.O. BOX 55874 BOSTON, MA 02205			ART UNIT	PAPER NUMBER
ŕ			2826	
			DATE MAILED: 03/29/2005	

Please find below and/or attached an Office communication concerning this application or proceeding.

	I A		<i>4</i> \#
	Application No.	Applicant(s)	
Office Assistant Comments	10/669,864	GRONBECK ET AL	
Office Action Summary	Examiner	Art Unit	
	Alexander O. Williams	2826	
The MAILING DATE of this communication Period for Reply	on appears on the cover sheet wit	h the correspondence address -	•
A SHORTENED STATUTORY PERIOD FOR F THE MAILING DATE OF THIS COMMUNICAT - Extensions of time may be available under the provisions of 37 of after SIX (6) MONTHS from the mailing date of this communicatile. If the period for reply specified above is less than thirty (30) days of the period for reply is specified above, the maximum statutory failure to reply within the set or extended period for reply will, by any reply received by the Office later than three months after the earned patent term adjustment. See 37 CFR 1.704(b).	ION. FR 1.136(a). In no event, however, may a re ion. s, a reply within the statutory minimum of thirty period will apply and will expire SIX (6) MONT statute, cause the application to become ABA	ply be timely filed (30) days will be considered timely. HS from the mailing date of this communica	ation.
Status			
1) Responsive to communication(s) filed on	02 December 2004.		
2a)☐ This action is FINAL . 2b)⊠	This action is non-final.		
3)☐ Since this application is in condition for a	llowance except for formal matte	rs, prosecution as to the merits	s is
closed in accordance with the practice ur	nder <i>Ex parte Quayle</i> , 1935 C.D.	11, 453 O.G. 213.	
Disposition of Claims			
4)⊠ Claim(s) <u>1-26</u> is/are pending in the applic	ation.		
4a) Of the above claim(s) <u>10-26</u> is/are wit			
5) Claim(s) is/are allowed.			
6)⊠ Claim(s) <u>1-9</u> is/are rejected.			
7) Claim(s) is/are objected to.			
8) Claim(s) are subject to restriction a	and/or election requirement.		
Application Papers			
9)☐ The specification is objected to by the Exa	ominor		
10) The drawing(s) filed on is/are: a)		v the Everines	
-	• • •	•	
Applicant may not request that any objection t			47.15
Replacement drawing sheet(s) including the c		•	
11)☐ The oath or declaration is objected to by t	ne Examiner. Note the attached	Office Action of form P10-152.	-
Priority under 35 U.S.C. § 119			
12) Acknowledgment is made of a claim for fo	reign priority under 35 U.S.C. §	119(a)-(d) or (f).	
a) All b) Some * c) None of:			
1. Certified copies of the priority docu	ments have been received.		
2. Certified copies of the priority docu	ments have been received in Ap	plication No	
3. Copies of the certified copies of the			
application from the International B	ureau (PCT Rule 17.2(a)).		
* See the attached detailed Office action for	a list of the certified copies not re	eceived.	
Attachment(s)			
1) Notice of References Cited (PTO-892)	4) T Interview Su	mmary (PTO-413)	
2) Notice of Draftsperson's Patent Drawing Review (PTO-94	8) Paper No(s)	Mail Date	
3) Information Disclosure Statement(s) (PTO-1449 or PTO/S		ormal Patent Application (PTO-152)	
Paper No(s)/Mail Date <u>8/4/04 and 11/22/0</u> . J.S. Patent and Trademark Office	6)	-·	
	fice Action Summary	Part of Paper No./Mail Date 20050	0301

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Serial Number: 10/669864 Attorney's Docket #: 51757

Filing Date: 9/24/03;

Applicant: Gronbeck et al.

Examiner: Alexander Williams

This application claims the benefit of provisional application number 60/413265, filed 9/24/02.

Applicant's election of species of figure 2A in which related to the complete species of figures 2A-2J (claims 1 to 9), filed 12/2/04, has been acknowledged.

This application contains claims 10 to 26 drawn to an invention non-elected with traverse.

The title of the invention is not descriptive. A new title is required that is clearly indicative of the invention to which the claims are directed.

The lengthy specification has not been checked to the extent necessary to determine the presence of all possible minor errors. Applicant's cooperation is requested in correcting any errors of which applicant may become aware in the specification.

Claims 1 to 9 are rejected under 35 U.S.C. § 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

In claims 1-9, it is unclear what is meant by the claimed structure being described a being removable. What is the final structure claimed.

Any of claims 1 to 9 not specifically addressed above are rejected as being dependent on one or more of the claims which have been specifically objected to above.

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The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains.

Patentability shall not be negatived by the manner in which the invention was made.

This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(f) or (g) prior art under 35 U.S.C. 103(a).

Initially, and with respect to claims 1 to 9, note that a "product by process" claim is directed to the product per se, no matter how actually made, In re Hirao, 190 USPQ 15 at 17 (footnote 3). See also In re Brown, 173 USPQ 685; In re Luck, 177 USPQ 523; In re Wertheim, 191 USPQ 90 (209 USPQ 554 does not deal with this issue); In re Fitzgerald, 205 USPQ 594, 596 (CCPA); In re Marosi et al., 218 USPQ 289 (CAFC); and most recently, In re Thorpe et al., 227 USPQ 964 (CAFC, 1985) all of which make it clear that it is the final product per se which must be determined in a "product by process" claim, and not the patentability of the process, and that, as here, an old or obvious product produced by a new method is not patentable as a product, whether claimed in "product by process" claims or not. Note that Applicant has burden of proof in such cases as the above case law makes clear.

Claims 1 to 9, **insofar as they can be understood**, are rejected under 35 U.S.C. § 103(a) as being unpatentable over Kessler et al. (U.S. Patent # 5,110,712). Claim 1. Kessler et al. (figures 1 to 5) specifically figure 4 show an electronic device comprising a first dielectric layer 14 comprising a first removable material, and a second dielectric layer 30 comprising a second removable material.

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Claim 2. The electronic device of claim 1, Kessler et al. further comprising an etch differentiating layer disposed between the first dielectric layer and the second dielectric layer.

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- Claim 3. The electronic device of claim 2, Kessler et al. show wherein the etch differentiating layer comprises a third removable material.
- Claim 4. The electronic device of claim 1 wherein at least one of the first removable material and second removable material comprises cross-linked polymeric particles.
- Claim 5. The electronic device of claim 1, Kessler et al. show wherein the first dielectric layer and the second dielectric layer have an etch differential of at least 1:2.
- Claim 6. The electronic device of claim 1, Kessler et al. show wherein both the first dielectric layer and the second dielectric layer are inorganic.
- Claim 7. The electronic device of claim 1, Kessler et al. further comprising a third layer on the second layer, wherein the third layer is inorganic.
- Claim 8. The electronic device of claim 7, Kessler et al. show wherein the third layer comprises a fourth removable material.
- Claim 9. The electronic device of claim 9, Kessler et al. show wherein the third layer has sufficient porosity to allow for removal of the first removable material and the second removable material through the third layer.

As to the grounds of rejection under section 103, see MPEP § 2113.

US 5110712 A May 5, 1992

INT-CL (IPC): G03C005/00, H01L021/31

BASIC-ABSTRACT:

A composite dielectric layer is formed in an integrated circuit to facilitate high density multi- level interconnects with external contacts through the use of high strength dielectric layers to support high stress metal layers. This composite dielectric layer is fabricated by:- (1) forming a polymer layer (20) on a first inorganic layer (14) to provide a planarised surface (22), (2) Depositing a second inorganic layer (24) on the planarised surface (22) to form an inorganic mast (30) for etching polymer layer (20), and (3) Etching polymer layer (20) using first inorganic layer (14) as an etch stop to allow long over etches to achieve full exposure of external contact surfaces of conductors to be connected to subsequently deposited metal layers (40, 42).

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A polyimide polymer layer (20) is deposited onto the underlying layers (14, 12), which include metal features (16, 18), by suspending in a solvent and uniformly distributing by spinning the integrated circuit device being formed. The 4000 Angstrom thick polymer layer (20) is pref. thermally cured to remove the solvent, after which it is baked at low temp. to drive out any moisture. Deposition of the second inorganic layer (24) pref. comprises applying SiO2 using either plasma enhanced CVD or atmos. pressure deposition or Si3N4 using plasma enhanced CVD. A masking layer (28) is then formed on the SiO2/Si3N4 layer (24) pref. by depositing a photoresist layer that is highly planarised so that small features can be transferred to the polymer layer exposing the photoresist layer photolithographically with a predetermined masking pattern, and etching.

ABSTRACTED-PUB-NO: US 5110712A

Composite dielectric sandwich is formed in an integrated circuit (I) by the use of inorganic dielectric layers. Firstly, a first inorganic dielectric layer (II) is formed, over at least one underlying layer of (I), that has sufficient strength to protect the underlying layer, by distributing stress from subsequently formed metal features that are deposited on layer (II).

First metal features are then formed on layer (II). A polymer layer (II) is formed over layer (II), and the first metal features to (I), layer (III) being uniformly distributed to provide a planarised surface. A second inorganic dielectric layer (IV) is then deposited in (I), over layer (III), that provides sufficient strength to protect layer (III) by distributing stress from subsequently formed second metal features that are deposited on layer (IV).

A mask is formed on layer (IV). Layer (IV) is etched, using the mask as a masking pattern, to form an <u>inorganic dielectric</u> mask (V), and to provide a protective layer for etching of any subsequently deposited <u>polymer</u> layers. Layer (III) is etched, using the mask (V) as a masking pattern, to <u>remove</u> all polymer unmasked by mask (V), between mask (V) and layer (II), such that layer (II) functions as a protective and <u>etch</u> stop for the underlying layers, wherever the etching of layer (III) continues after all the unmasked polymer has been <u>removed</u> to fully expose any existing external contact surfaces of the

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first metal features. Layer (IV) is maintained as an insulating layer that, together with layer (III), forms the composite dielectric sandwich that has sufficient strength to distribute stress from subsequently formed second metal features and that remains in (I) as an etch stop layer for subsequently formed layers in a multilayer integrated circuit. Finally, second metal features are formed on layer (IV) on in vias formed by etching layer (III).

ADVANTAGE - etch selectivity concerns between the polymer and the photolithographic mask are eliminated, allowing small features to be easily transferred into the polymer using standard dry etch techniques.

The listed references are cited as of interest to this application, but not applied at this time.

Field of Search	Date
U.S. Class and subclass: 257/700,701,758,760,759	3/2/05
Other Documentation: foreign patents and literature in 257/700,701,758,760,759	3/2/05
Electronic data base(s): U.S. Patents EAST	3/2/05

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Alexander O. Williams whose telephone number is (571) 272 1924. The examiner can normally be reached on M-F 6:30-7:00PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nathan Flynn can be reached on (571) 272 1915. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Alexander O Williams Primary Examiner Art Unit 2826 Page 7

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